## IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): <u>Process A process</u> for manufacturing a fragmented layer of material [[(14)]] on a support, <u>characterised in that it comprises comprising</u>:

- [[-]] a deposition step for depositing, in a discontinuous manner, a thin layer [[(14)]] of this material on said support, in a discontinuous manner, and
  - [[-]] followed by a step for putting this thin layer into drops.

Claim 2 (Currently Amended): <u>Process The process</u> according to claim 1, wherein putting into drops is achieved by heat treatment.

Claim 3 (Currently Amended): <u>Process The process</u> according to claim 1, wherein putting into drops is achieved by hydrogen plasma treatment at low temperature.

Claim 4 (Currently Amended): Process The process according to any of claims claim

1 to 4, further comprising a previous step for depositing a thermal or diffusion barrier layer

[[(12)]].

Claim 5 (Currently Amended): Process The process according to claim 4, wherein the thermal or diffusion barrier layer (12) being is made of TiN[[,]] and the material being is nickel.

Claim 6 (Currently Amended): Process The process according to any of claims claim 1 to 5, wherein the material is a metal.

Claim 7 (Currently Amended): Process The process according to one of claims claim 1 to 6, wherein the deposition step of the material layer being is performed in the presence of an oxygen partial pressure.

Claim 8 (Currently Amended): Growth A growth process of carbon nanotubes or nanofibres nanofibers, comprising:

- [[-]] production of producing a catalytic metal layer according to any-of claims claim 1 to 7, and
- [[-]] growth of growing nanotubes or nanofibres nanofibers on the catalyst layer thus obtained.

Claim 9 (Currently Amended): Process The process according to claim 8, wherein the growth of nanotubes or nanofibres nanofibers being is obtained by chemical vapour vapor phase deposition.

Claim 10 (Currently Amended): Process A process for producing a surface with controlled roughness on a support, comprising:

[[-]] production of producing a fragmented thin layer of material on this support, according to any of claims claim 1 to 7.

Claim 11 (Currently Amended): Process The process according to claim 10, further comprising:

- [[-]] formation of forming an oxide layer on the material layer thus formed; and
- [[-]] a polishing step.

Claim 12 (Currently Amended): Process A process for producing a metal/oxide mix on the surface of a support, including comprising:

- [[-]] production of producing a fragmented thin layer of a metallic material on this support, according to any of claims claim 1 to 7.
  - [[-]] formation of forming an oxide layer on the layer of material thus formed, and
  - [[-]] a polishing step.

Claim 13 (New): A process for manufacturing a fragmented layer of material on a support comprising the succession of:

a deposition step of a diffusion or thermal barrier layer,

a deposition step for depositing, in a discontinuous manner, a thin layer of this material, preferably a metal, on said barrier layer, and

a step for putting this thin layer into drops.

Claim 14 (New): The process according to claim 13, wherein putting into drops is achieved by heat treatment or by hydrogen plasma treatment at low temperature.

Claim 15 (New): The process according to claim 13, wherein the deposition step of the material layer is performed in the presence of an oxygen partial pressure.

Claim 16 (New): A growth process of carbon nanotubes or nanofibers, comprising: producing a catalytic metal layer according to claim 13, and growing of nanotubes or nanofibers on the catalyst layer thus obtained.

Docket No. 294550US Preliminary Amendment

Claim 17 (New): The process according to claim 16, wherein the growth of nanotubes or nanofibers is obtained by chemical vapor phase deposition.

Claim 18 (New): A process for producing a surface with controlled roughness on a support, comprising:

producing of a fragmented thin layer of material on this support, according to claim 13.

Claim 19 (New): The process according to claim 18, further comprising: forming an oxide layer on the material layer thus formed; and a polishing step.

Claim 20 (New): A process for producing a metal/oxide mix on the surface of a support, including:

producing a fragmented thin layer of a metallic material on this support, according to claim 13;

forming an oxide layer on the layer of material thus formed, and a polishing step.